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**REPLY UNDER 37 CFR 1.116 EXPEDITED PROCEDURE TECHNOLOGY CENTER - 2800** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Maldei, et al.

9727329218

Docket No.: INTECH 3.0-083

(2002 P 15183 US)

Serial No.:

10/619,884

Art Unit:

2823

Filed:

July 15, 2003

Examiner:

Brook Kebede

Title:

Method to Improve Bitline Contact Formation Using a Line Mask

Mail Stop: AF

Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

## AMENDMENT AFTER FINAL REJECTION

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed September 12, 2005. Entry of this amendment is requested to place the application in condition for allowance or to place the claims in a better condition for appeal. Please amend the claims as follows:

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Amendment After Final